

# LA-306

### COMPACT HIGH TEMPERATURE INFRARED FURNACE

- Production and Laboratory Applications
- 9 30-inch IR Heat Chamber, up to 1000°C
- 3 Separately Controlled Heat Zones
- Controlled CDA, N2, & FG Process Atmospheres
- Dual gas option (N2 & Forming Gas) for Low O2
- BRAND NEW Digital Control System



#### THE LA-306 FURNACE

A compact 3-zone furnace, this furnace is small enough to be used in a laboratory setting and robust enough to often be used for production applications. This model is approximately 10 feet (3070 mm) long and 2 feet (500 mm) wide. The LA-306 has a 6-inch (150 mm) wide belt and 2-inch (50 mm) high product opening. The small chamber offers excellent temperature control and rapid rise to 1000°C. The newly designed control system is easy to use and provides sophisticated zone temperature control. Upper and lower lamps can be independently enabled to operate the furnace in radiant mode, radiant convection mode, or convection mode.

*IR color.* Depending on supply voltage, the furnace will operate in the IR wavelength of 1900-2600 kelvin. Voltage compensation assures the lamps operate consistently at the design color temperature.

#### WHERE IT IS USED (ENVIRONMENT)

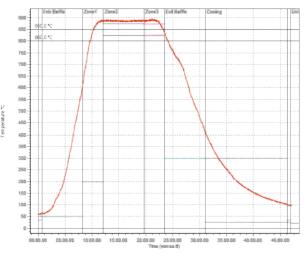
It is used in production and laboratory environments for thermally controlled continuous processes in a controlled atmosphere of nitrogen, forming gas or air. The furnace can heat to 1000C or ~1800F and typically reaches stable process ready in 30 minutes. It is available in a dual gas configuration, a second gas such as forming gas composed of nitrogen and up to 4% hydrogen can be introduced into the furnace chamber while pure nitrogen is used in the rest of the furnace. It runs on single phase 208-240 volt (50/60 Hz) power. It is efficient: when operated at 800°C it draws only 40 amps of current.

#### **HOW IT IS USED (TYPICAL APPLICATIONS)**

The LA-306 is used thermal processing of substrates, wafers, PCBs, metal ingots and manufactured parts, ceramic, glass, optical coatings and polycarbonate products. Specific applications include:

- General Curing and Drying
- Semiconductor processing, Package sealing, Epoxy Die Attach, Polymer Curing
- Advanced thin film, crystalline silicone, cadmium telluride (CdTe alloys) and certain copper indium diselenide (CISalloys) solar cell processing

The LA-306 furnace is popular for dental labs and dental production applications.



Typical LA-306 880°C Temperature Profile



## EQUIPMENT SPECIFICATIONS

DOC NBR: STD		- 802-101401					1	R1
MODEL: LA-306		CUSTOMER:					<u> </u>	
SERIAL NBR:	ALL	SHT	1	OF	1		PRN	T 03/14/13

Equipment M	adal									
Equipment Model			01-	al Zanaa	F	antad Law-th	NI	nol Europea Dolt Wilde		
	Base Equipment  Continuous Belt Controlled			ol Zones	Furnace H	eated Length	Nominal Furnace Belt Width			
LA-306	Atmosphere Furnace		3		30 in	30 in 762 mm		152 mm		
Equipment A	rrangement									
Phase	Process			Max	Le	ngth	Process Gas	Temperature (typ)		
Phase 1	IR Furnace, 3 Zones		1000 °C		30 in	30 in 762 mm		450-950 C		
Phase 2 Transition Tunnel						381 mm	N2	450-750 C		
Gas Convective Cooling, Exterior			n Heat Remo	oval	30 in	762 mm	N2	35-450 C		
<b>Process Sect</b>	ions									
Function					Length		Process Gas	Temperature (typ)		
Product Load	Load Station		Entrance lo	ad area	15 in 381 mm		none	ambient		
	Entr Baffle/Entrance Eductor		Entrance ba			15 in 381 mm		410 °C		
Zone 1		Heating chamber 1		7.5 in	191 mm	FG	800 °C			
IR Furnace	Zone 2		Heating chamber 1		15 in	381 mm	FG	850 °C		
	Zone 3		Heating chamber 1		7.5 in	191 mm	FG	850 °C		
		Heat/cool b	arrier, single	15 in	381 mm	N2	510 °C			
Cooling	Gas Convection Cooling		Cooling section		30 in	762 mm	N2	295 °C		
Product Unload			Exit unload area		30 in		none	ambient		
	Frame Adjustment		1		1 in		-	1		
	Total				136 in					
Process Gas	1					2.0				
1100000 000	Actual Conditons		Tv	/pical	Typical	(Low O2)	Max (all flowmeters open)			
Furnace Replenis	shment Rate		2.0 rep/min			rep/min	6.1 rep/min			
	Temp Press		Min Flow	/ Min Flow	Typica	Typical		Max Compressor		
	°C ps		scfh		scfr		scfh	sL/m		
N2 Supply	21 70		143	67. 5	168	79	662	312		
FG Supply	21 70		35	17	121	57	417	197		
TOTAL PROCESS GAS			178	84	289	137	1,078	509		
<b>Exhaust Gas</b>										
	Temp Press		Min Flow Min Flow		, , ,	Typical Typical		Maximum Exha		
°C in H <sub>2</sub> O			scfh		scfr		scfh	sL/m		
N2 & FG mix	200 6		89	42	77	37	348	164		
Cabinet Venti		T=-								
Cabinet Ventilation		Flowrate			550 cfm	930 m3/h				
(vent to room or e Control Cabinet \	, , , , , , , , , , , , , , , , , , ,	Temperatu Flowrate	ire		<86°F 212 cfm	<30°C 360 m3/h				
(vents to room)	rentilation Fans		ıro		<86°F	<30°C				
,	-4	Temperatu	ii e		<00 F	<30 C				
Transport Sys	stem	6.0 in	450.4		5 // 5					
Belt width	152.4 mm		Belt E	Edge Heater(s): none						
, , , , , , , , , , , , , , , , , , ,			spiral weave nm) above b			Baffle plate clearance: 0.5" above belt				
3			iiii) above t	Deit level.		25-500 mm/m				
		1-20 ipm	1/ 4 F !	odiustal-1-			1/ 20 1 mm adjustable			
Conveyor height	.4	36.0 in	+/- 1.5 in	adjustable		914.4 mm	+/-38.1 mm	adjustable		
Electrical Sys	stem	00011 =	2011 151							
Voltage required	roquirod		50 Hz, 1 Ph							
			/, 78.2 A							
		8.8 kW, 40	A							
Materials of C		lo ::	A lease 1	-i 0		la	NICE 2.1	000/14:000/0 10/ 5		
Heating Chamber	304 Stainless steel	Cooling	Aluminum,			Belt		, 80%Ni,20%Cr, <1% Fe		
Baffle & Eductor	304 Stainless steel	Belt support	-	Quartz tube				Steel, epoxy or powder coated  18GA steel, epoxy coated		
Heating element	Quartz, near infrared	Belt Return	UHMW-PE			Cover Panels	INGA steel,	epoxy coated		
Furnace Dime		147.10				IE	0 1 0 1	T / 151 / 150		
English	Length	Width		Height (floor to s	,	Furnace Sect	Coolg Sectn	Total Net Wt		
English	136 in	25 in			+/- 1.5 in	1150 LB	none	1150 LB		
Metric	3454 mm 635 mm English 145 in 34 in				+/- 38.1 mm 530 kg		none Gross Wt:	530 kg		
, <u> </u>				84 in			Gross Wt:	1673 kg		
Crate, Metric 3683 mm		864 mm		2134 mm		Tamer and	Gross Wt:	760 kg		
Standard Conditions		Pressure	14.7 psia	101.3 kPa		Temperature	70 °F	21 °C		